| Notice of Allowability   | Application No.                          | Applicant(s)                  |
|--|--|-------------------------------|
|  | 09/929,789                               | TISCHLER ET AL.               |
|  | Examiner                                 | Art Unit                      |
|  | Matthew J. Song                          | 1722                          |
| The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308. |  |                               |
| 1. This communication is responsive to <u>4/4/2005</u> .   |  |                               |
| 2.  The allowed claim(s) is/are <u>61,63-66,70 and 71</u> .  |  |                               |
| 3. The drawings filed on 14 August 2001 are accepted by the Examiner.  |  |                               |
| <ul> <li>4.  Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a)  All b)  Some* c)  None of the:</li> <li>1.  Certified copies of the priority documents have been received.</li> <li>2.  Certified copies of the priority documents have been received in Application No</li> <li>3.  Copies of the certified copies of the priority documents have been received in this national stage application from the</li> </ul>  |  |                               |
| International Bureau (PCT Rule 17.2(a)).   |  |                               |
| * Certified copies not received:   |  |                               |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.   |  |                               |
| 5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.   |  |                               |
| 6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.   |  |                               |
| (a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached   |  |                               |
| 1)  hereto or 2)  to Paper No./Mail Date   |  |                               |
| (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date   |  |                               |
| Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).  |  |                               |
| 7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.  |  |                               |
| Attachment(s)  |  |                               |
| 1. Notice of References Cited (PTO-892)  |  | Patent Application (PTO-152)  |
| 2. Notice of Draftperson's Patent Drawing Review (PTO-948)   | 6. ☐ Interview Summa<br>Paper No./Mail D |                               |
| 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date _ ◄// ← / >>>   |  |                               |
| 4. Examiner's Comment Regarding Requirement for Deposit  | 8. X Examiner's Stater                   | nent of Reasons for Allowance |
| of Biological Material   | 9.                                       |                               |
|  |  |                               |
|  |  |                               |
|  |  |                               |

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## **EXAMINER'S AMENDMENT**

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Steven Hultquist on 6/20/2005.

The application has been amended as follows:

- Cancel claim 67.
- In claim 61, line 2, insert "having an etch stop layer thereon," after "heterogeneous to GaN," and before "removing the heterogeneous".
- In claim 63, line 2, insert "wherein the one or more intermediate layers includes an etch stop layer" after "having one or more intermediate layers thereon;".

## Allowable Subject Matter

2. The following is an examiner's statement of reasons for allowance: The closest prior art is Akad (DD 224341 A1). Akad teaches a method of deposition an epitaxial layer of GaN on a substrate and removing a sapphire substrate. Akad also teaches a thin layer (some 10 angstroms) of boron nitride (BN) is used as a thin release layer between the sapphire substrate and the GaN

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film (page 2 of the translation provided by applicant). Akad discloses using a 10 angstrom thick layer, which too thin to be used as an etch stop layer; therefore Akad does not teach or suggest growing a single crystal GaN over a substrate having an etch stop layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Ceglio et al (US 4,870,648) teaches forming a boron nitride etch stop layer with a thickness of 10-200 nm (claims 10-12), which is 10-200 times the thickness taught by Akad (DD 224341 A1).

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew J. Song whose telephone number is 571-272-1468. The examiner can normally be reached on M-F 9:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Duane Smith can be reached on 571-272-1166. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Matthew J Song Examiner Art Unit 1722

MJS June 24, 2005

> ROBERT KUNEMUND PRIMARY EXAMINER